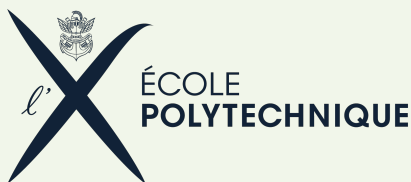


# Recent Progress on Laser-Plasma Acceleration at kHz repetition rate

**Jérôme Faure**

*Laboratoire d'Optique Appliquée  
Ecole Polytechnique, France*



# Motivations

kHz lasers → kHz secondary electron source

With current kHz lasers : tens of mJ energy

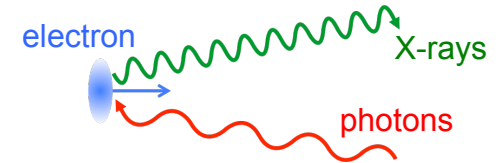
- “Low energy”, 1-20 MeV adapted to some applications
- Few femtosecond duration / jitter free with respect to laser
- few femtosecond resolution in pump-probe experiments
- Compact system (turn key ?) + high repetition rate
- stability, averaging, statistics, active feedback loops

# Motivations: making a LWFA at kHz

- **Electrons for driving a fs X-ray source @ kHz:**

20 MeV electrons  $\rightarrow$  10 keV X-ray via Compton scatt.

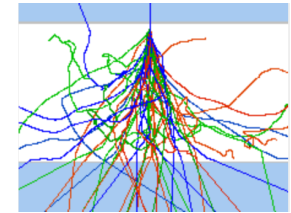
for fs diffraction, fs absorption (Ta Phuoc, Nat. Phot. 2012)



- **Electrons as a pump for femtosecond irradiation:**

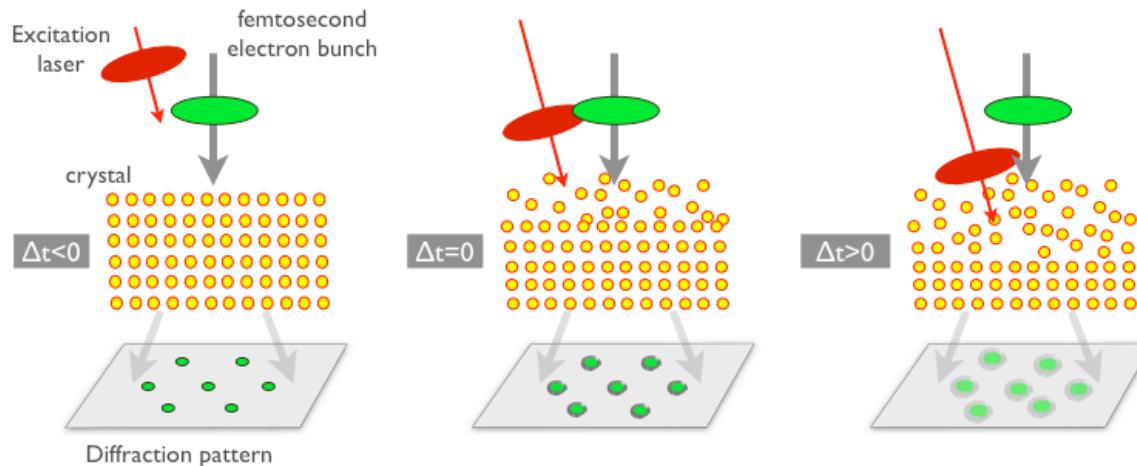
pulsed radiolysis (Muroya, Rad. Phys. Chem. 2008)

radiation hardness studies (Hidding et al., Sci. Rep. 2017)



- **Electrons as a probe: ultrafast electron diffraction for watching atomic motion in real time in complex materials**

(Mourou & Williamson, APL 41, 44 (1982), Miller, Science 343, 1108 (2014) )





# Outline of the talk

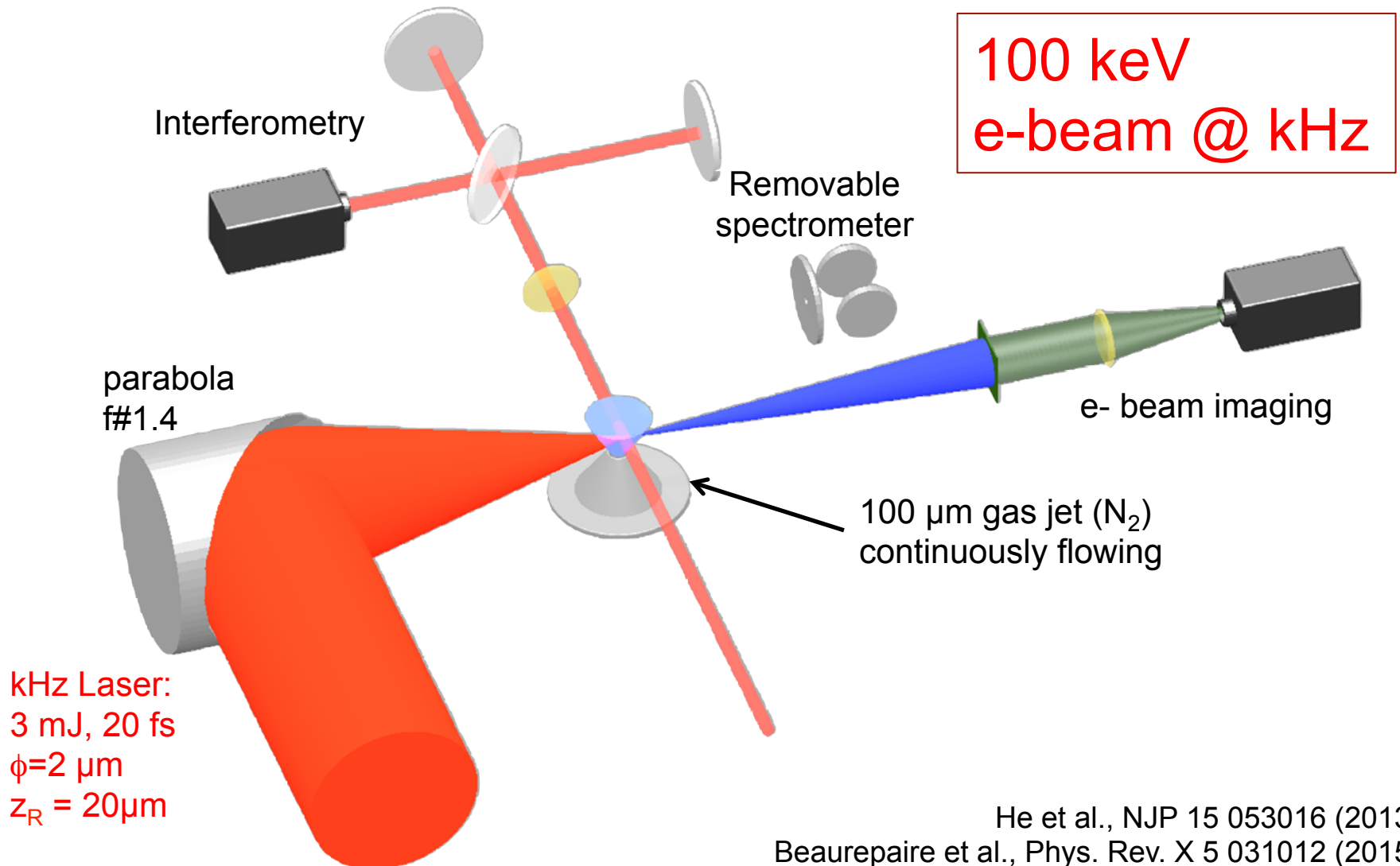
- **Review of experimental results at kHz**
- Physics of few cycle laser pulses
  - Carrier envelope phase effects
  - Dispersion effects



# First results at kHz in non resonant condition

**Michigan:** 35 fs, 8 mJ,  $I=3\times 10^{18}$  W/cm<sup>2</sup>, 500 Hz

**LOA:** 20 fs, 3 mJ,  $I=3\times 10^{18}$  W/cm<sup>2</sup>, 1 kHz

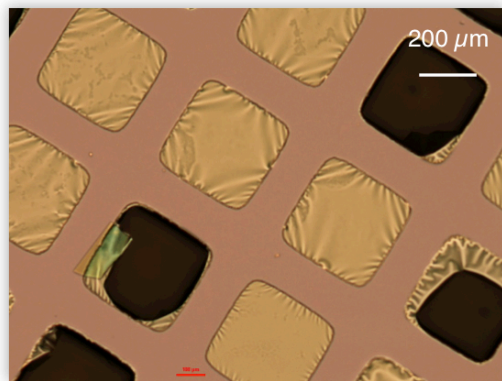


# Time-resolved diffraction experiment

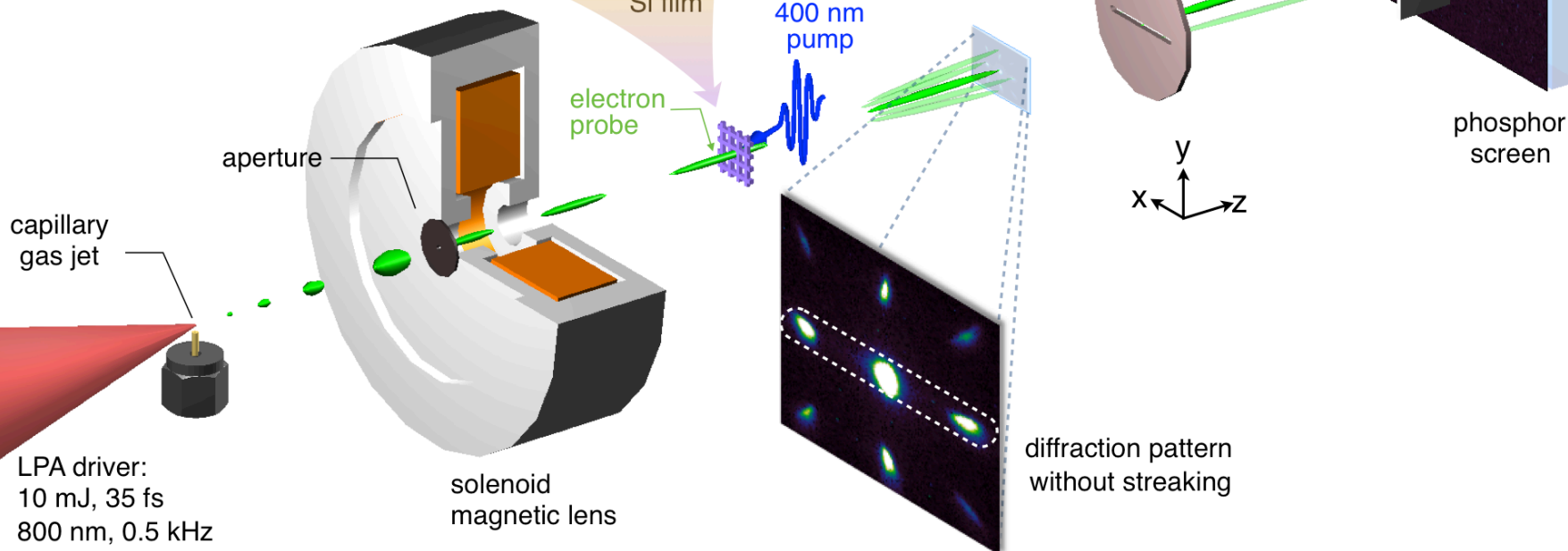
With 100 keV electrons



**30 nm Si nano membrane,**  
S. Scott, M. Lagally, Univ. Wisconsin



Si film

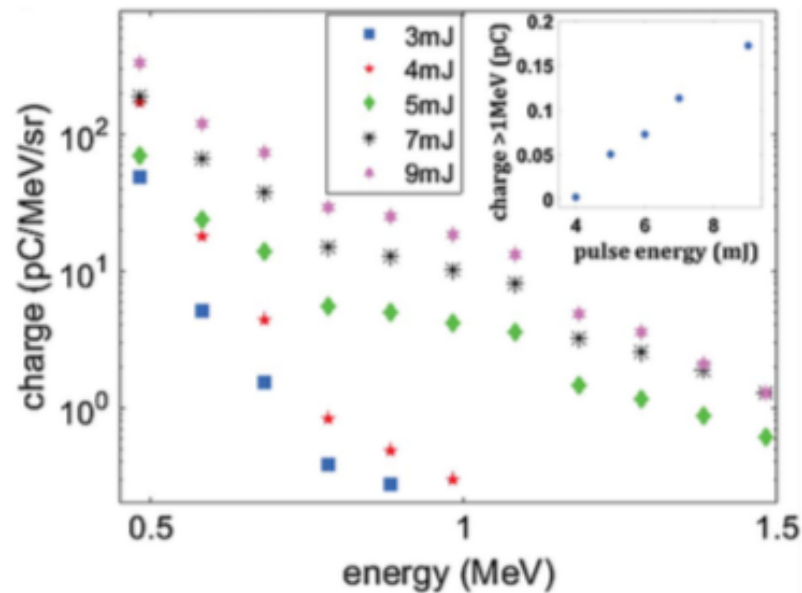
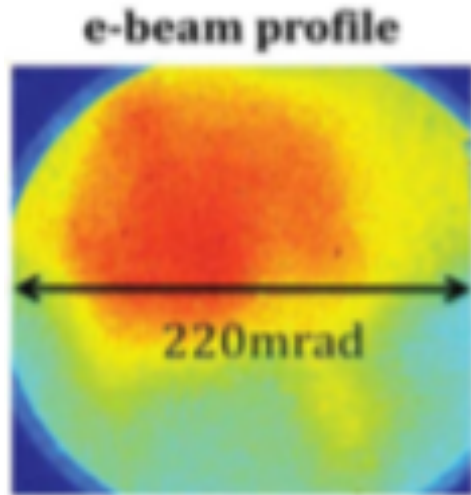


# Maryland 2017: Salehi et al., OL 42 215 (2017)

Laser: ~10 mJ , 30 fs @ 1 kHz

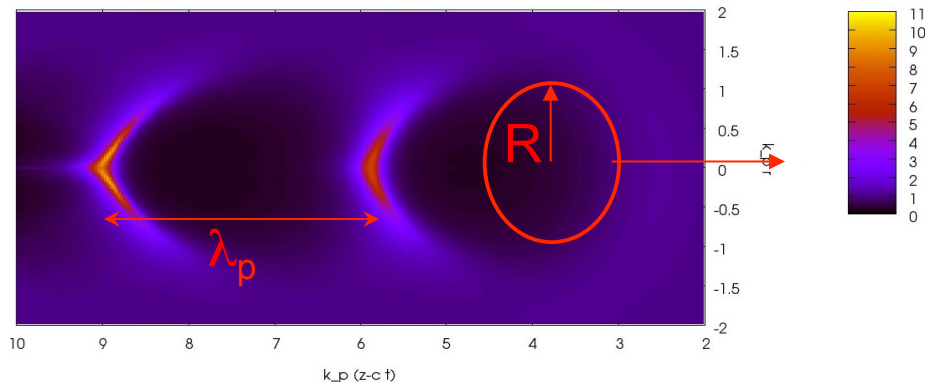
cooled gas jets: high density  $n_e = 4 \times 10^{20} - 8 \times 10^{20} \text{cm}^{-3}$

High density required for self-focusing  $P_c [GW] = 17.4 \frac{n_c}{n_e}$



MeV electrons, broad angular and spectral distributions

# Scaling laws toward kHz lasers: resonance condition



Laser pulse has to be  
resonant with plasma wave:  
 $R \approx \lambda_p/2$ ,  $c\tau \approx \lambda_p/2$

Laser energy scaling  $E_L \propto \tau^3 \propto \lambda_p^3$     Electron energy gain  $\Delta E \propto \tau^2 \propto \lambda_p^2$

30 fs  $\rightarrow$  1 J  $\rightarrow$  100 MeV-1 GeV

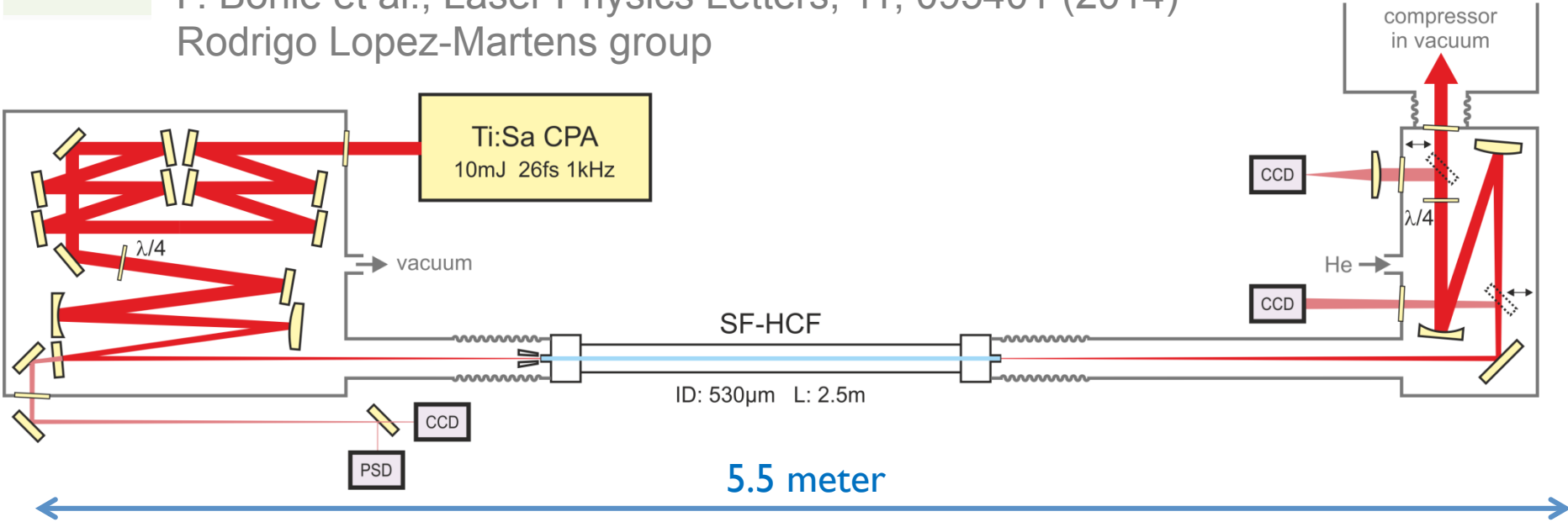
3 fs  $\rightarrow$  mJ  $\rightarrow$  1-10 MeV

and high density  $n_e > 10^{20} \text{ cm}^{-3}$

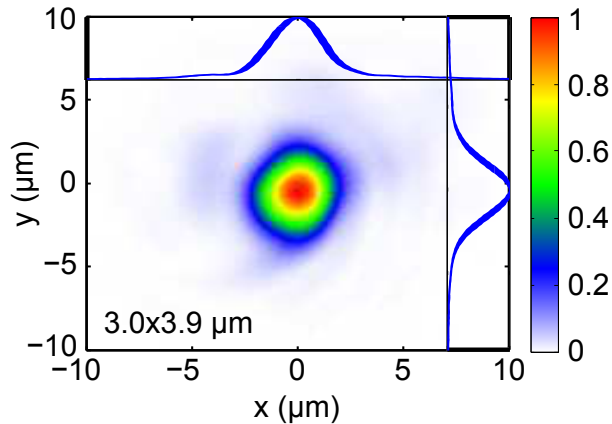
***Laser pulses of 5 fs, few mJ  $\rightarrow$  possible @ kHz !***

# 1 TeraWatt few-cycle kHz laser system

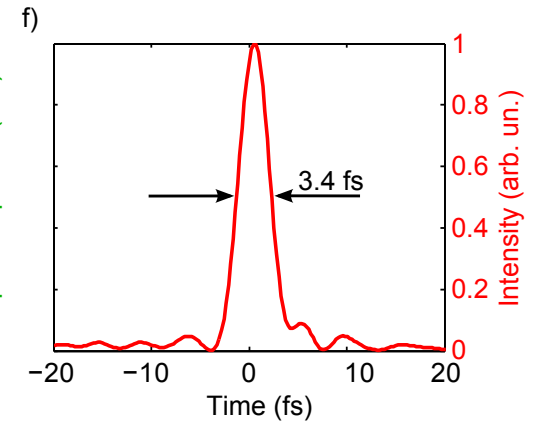
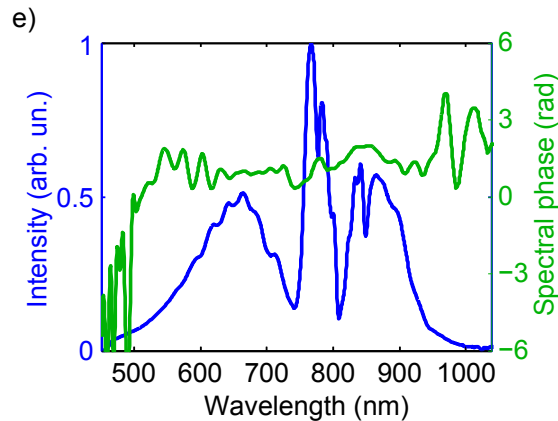
F. Böhle et al., Laser Physics Letters, 11, 095401 (2014)  
Rodrigo Lopez-Martens group



a) 3 mJ, focused to 3  $\mu$ m



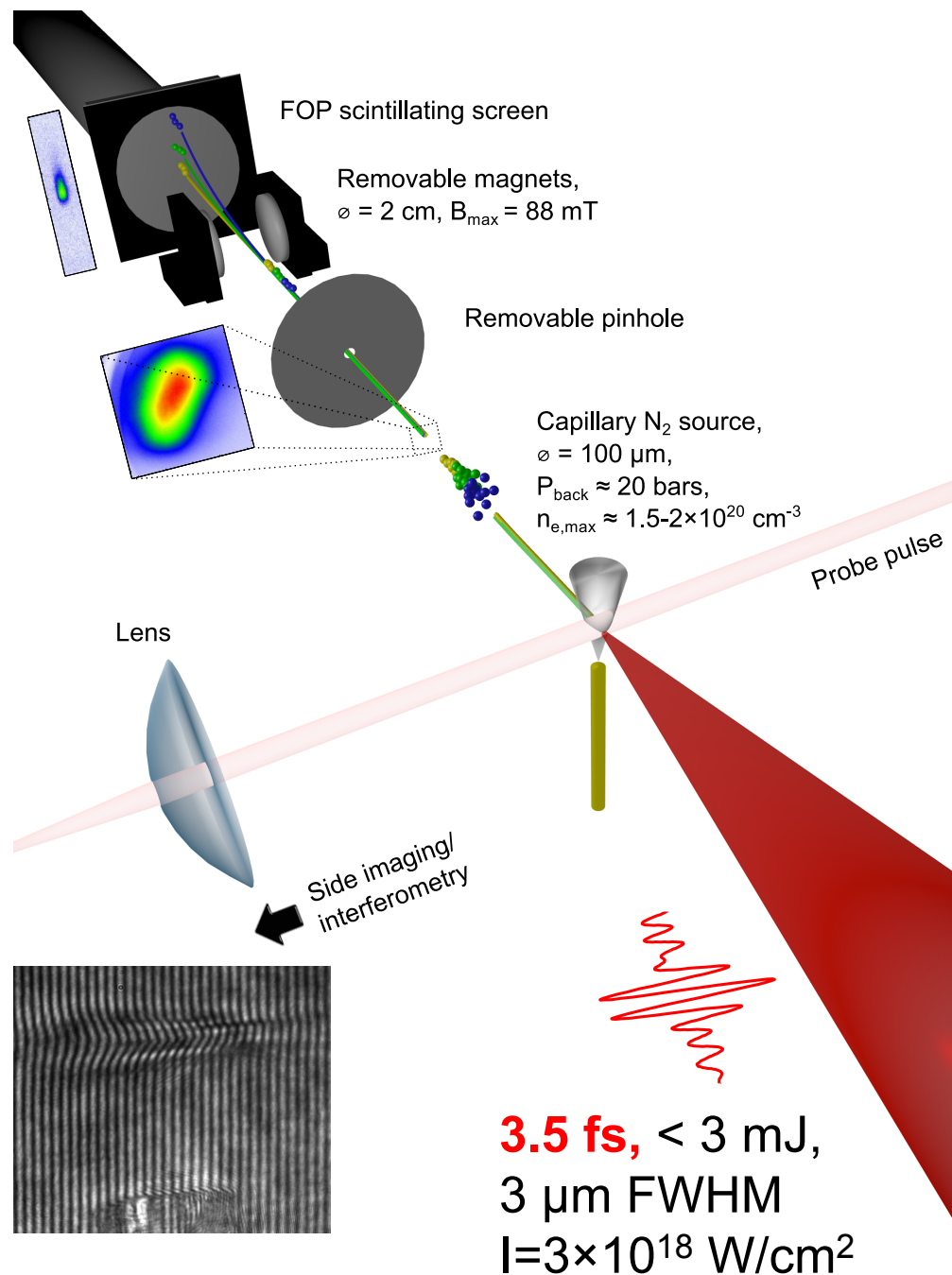
3.5-fs  $\sim$  single cycle pulse



# Experimental set-up

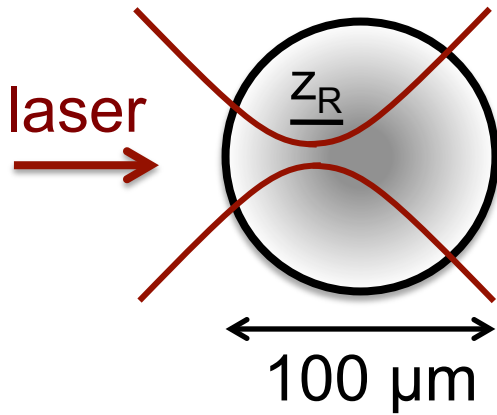
*Gas target is a continuously flowing capillary N<sub>2</sub> gas jet*

→ kHz operation !

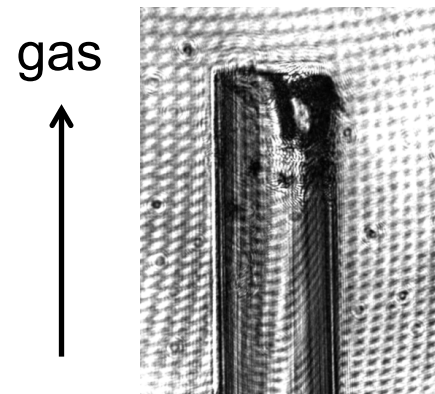
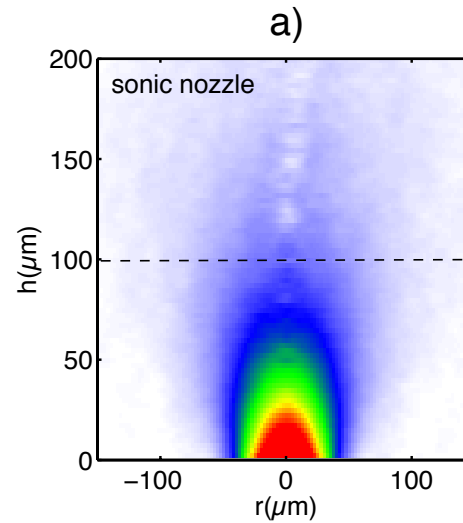


# Microscale gas jets

## Microscale accelerator



Rayleigh length: 20  $\mu\text{m}$   
Acceleration length: 20  $\mu\text{m}$



Glass capillary

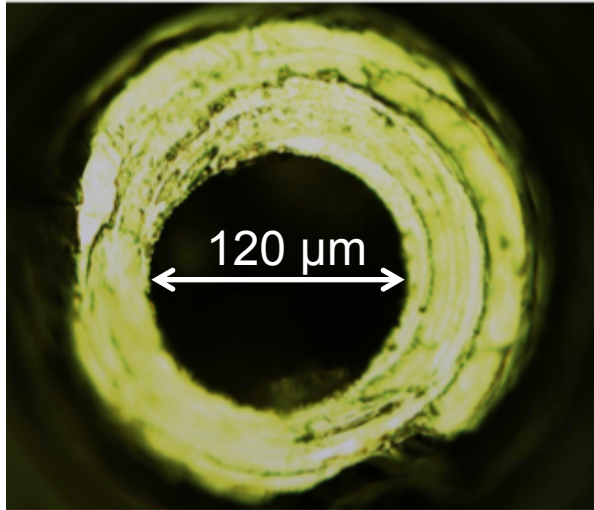


Supersonic jet



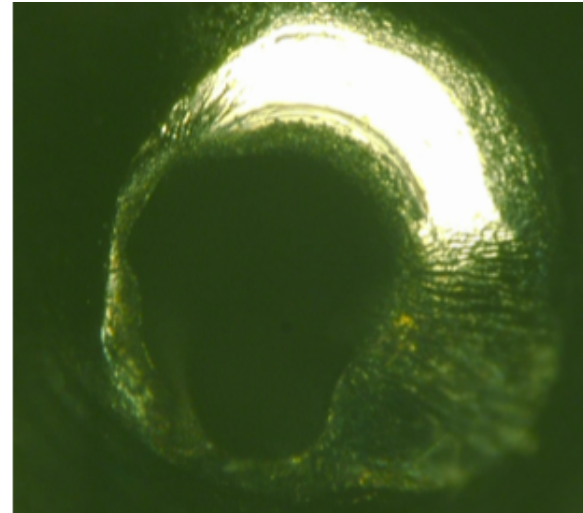
# The challenge of microjets for kHz LWFA

*Before experiment*



Top view of jet

*After 7 days, 4-6 hours/day @ kHz*



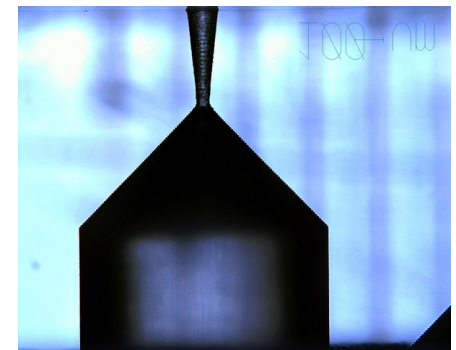
Damaged orifice

Next: dielectric jets for higher resistance

FLICE: fs laser irradiation and chemical etching

Vidmantas Tomkus group  
ICPT, Lithuania

side view of jet

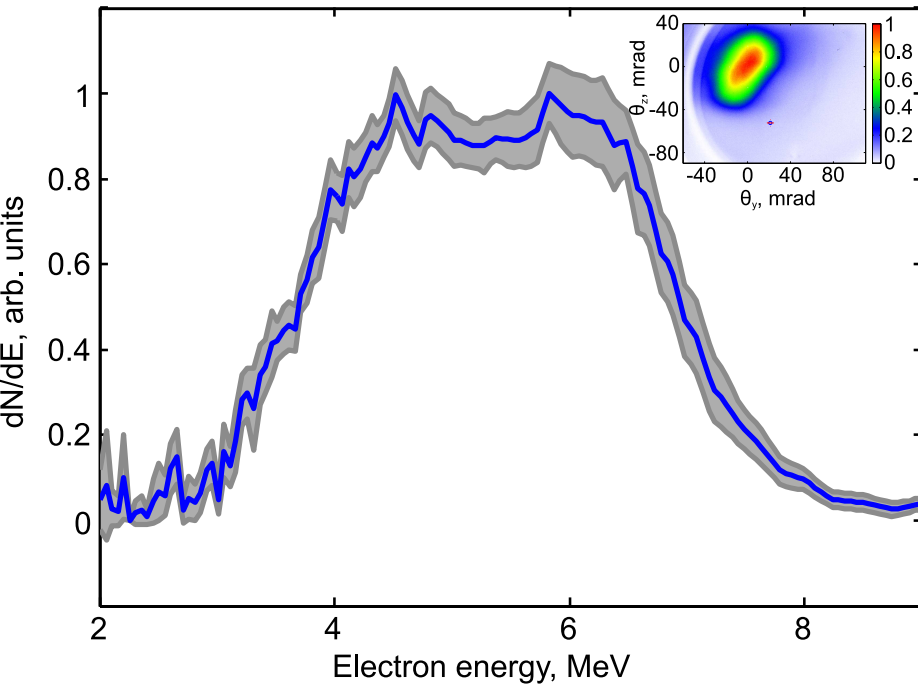




# MeV beams at kHz repetition rate

With subsonic jet

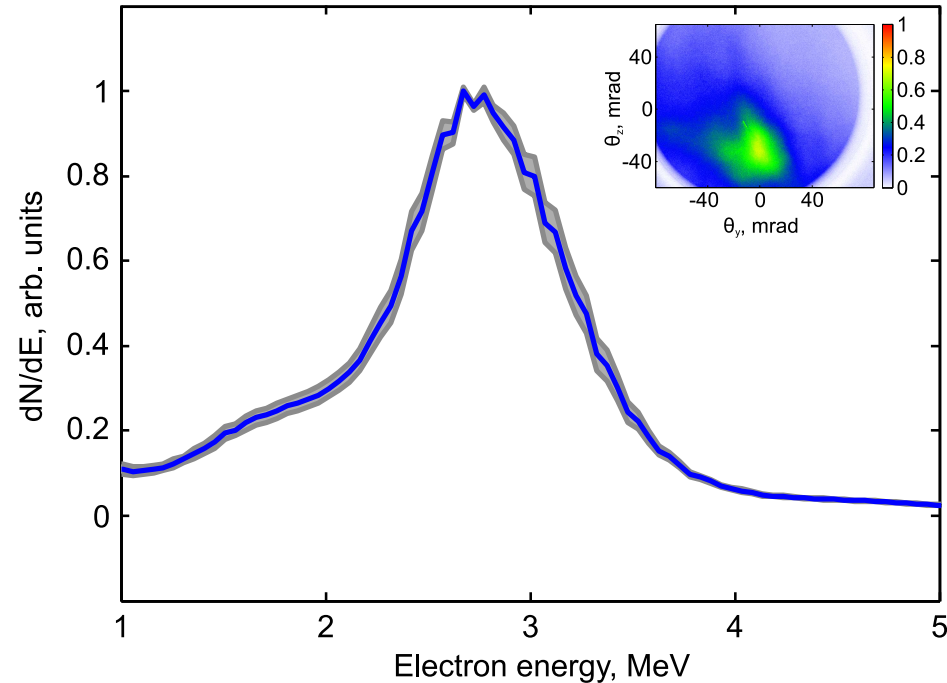
$$n_e = 1-2 \times 10^{20} \text{ cm}^{-3}, I = 3 \times 10^{18} \text{ W/cm}^2$$



~40 mrad divergence  
~100 fC, 30% rms fluc

With supersonic jet

$$n_e = 1-2 \times 10^{20} \text{ cm}^{-3}, I = 5 \times 10^{18} \text{ W/cm}^2$$



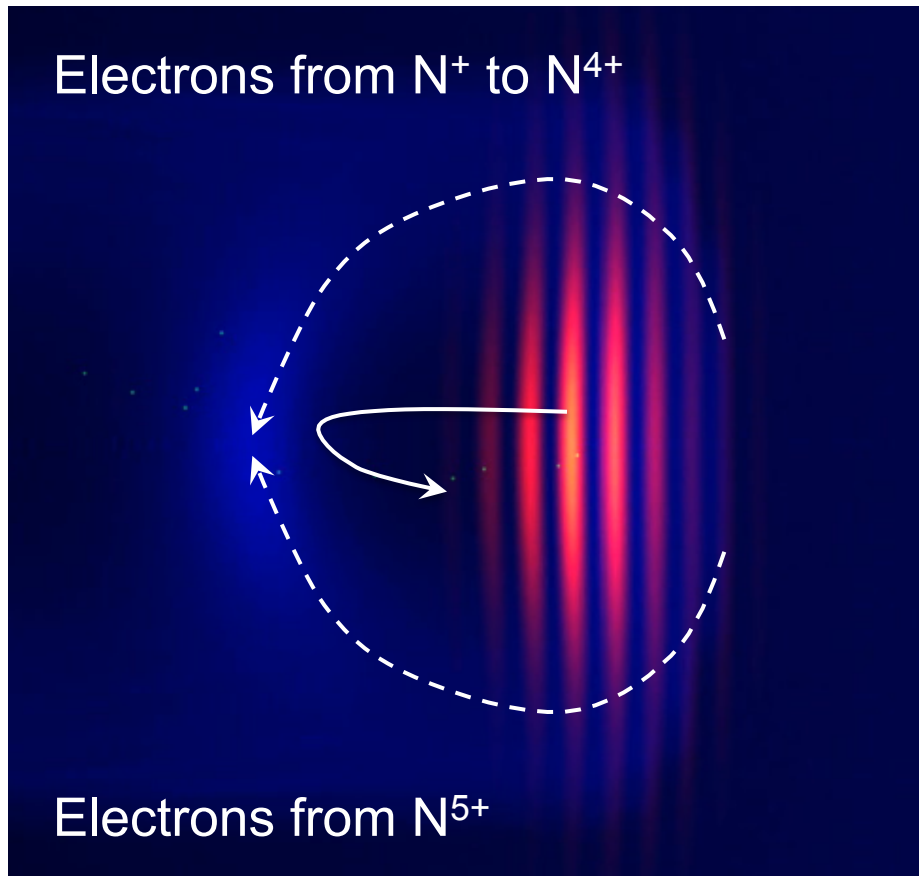
**100 times more charge**  
~20 pC, 10% rms fluc

# Ionization induced injection

$N^+$	$N^{1+}$	$N^{2+}$	$N^{3+}$	$N^{4+}$	$N^{5+}$
14.5eV	29.5eV	47.7eV	77.2eV	97.8eV	551eV

$I < 10^{16}$  W/cm<sup>2</sup> : plasma electrons

$I > 10^{18}$  W/cm<sup>2</sup> : beam electrons  
→ injection

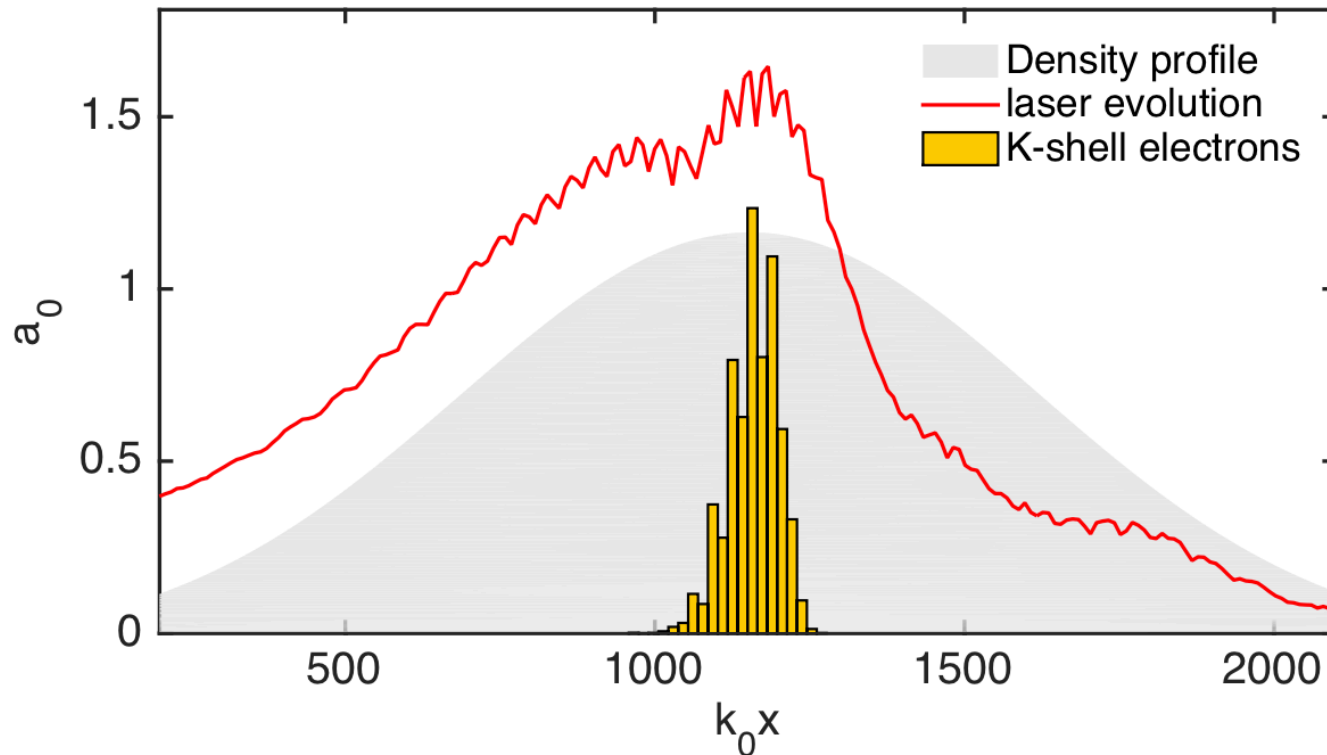


The most intense half cycles:

- ionize  $N^{5+}$
- inject a sub-fs bunch
- depends on CEP

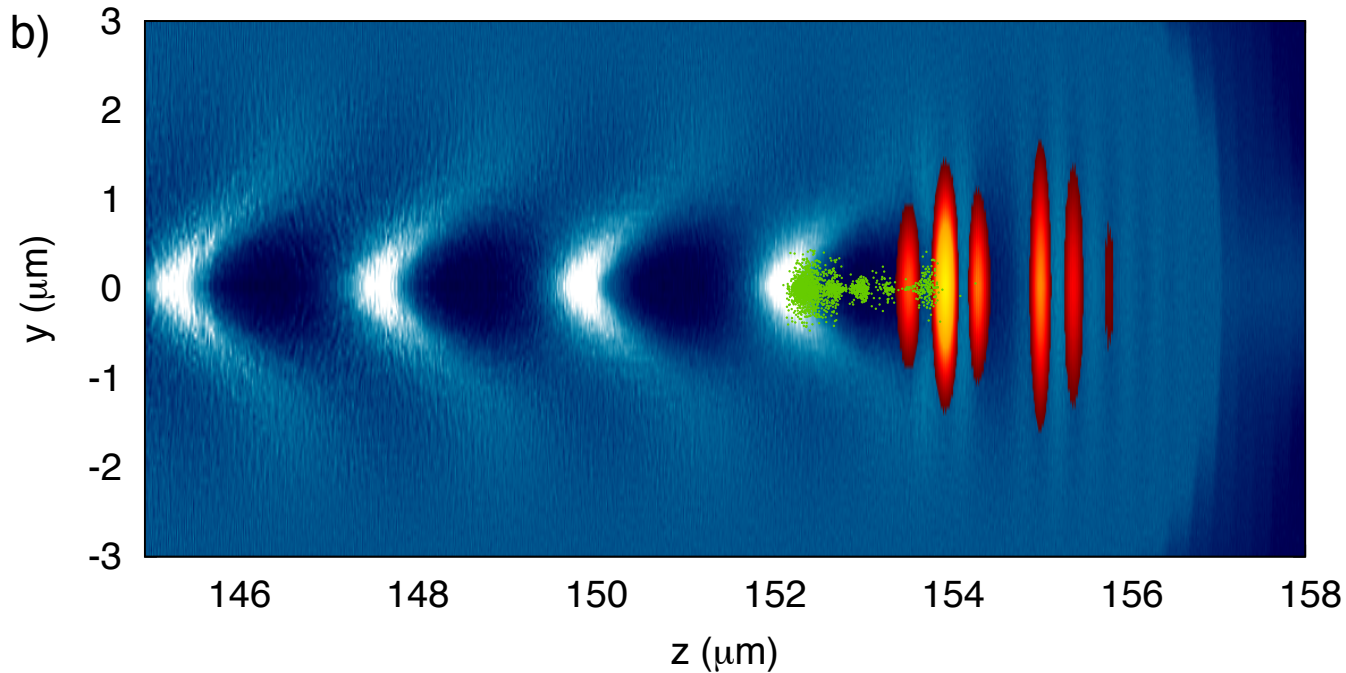
# PIC simulations for subsonic jet case → localized ionization injection

Accelerated electrons originate from the K-shell  
Injection length  $L_{inj} < 10 \mu\text{m}$



# PIC simulations $\rightarrow$ 1 fs electron beams !

Trapped electrons in non linear wakefield



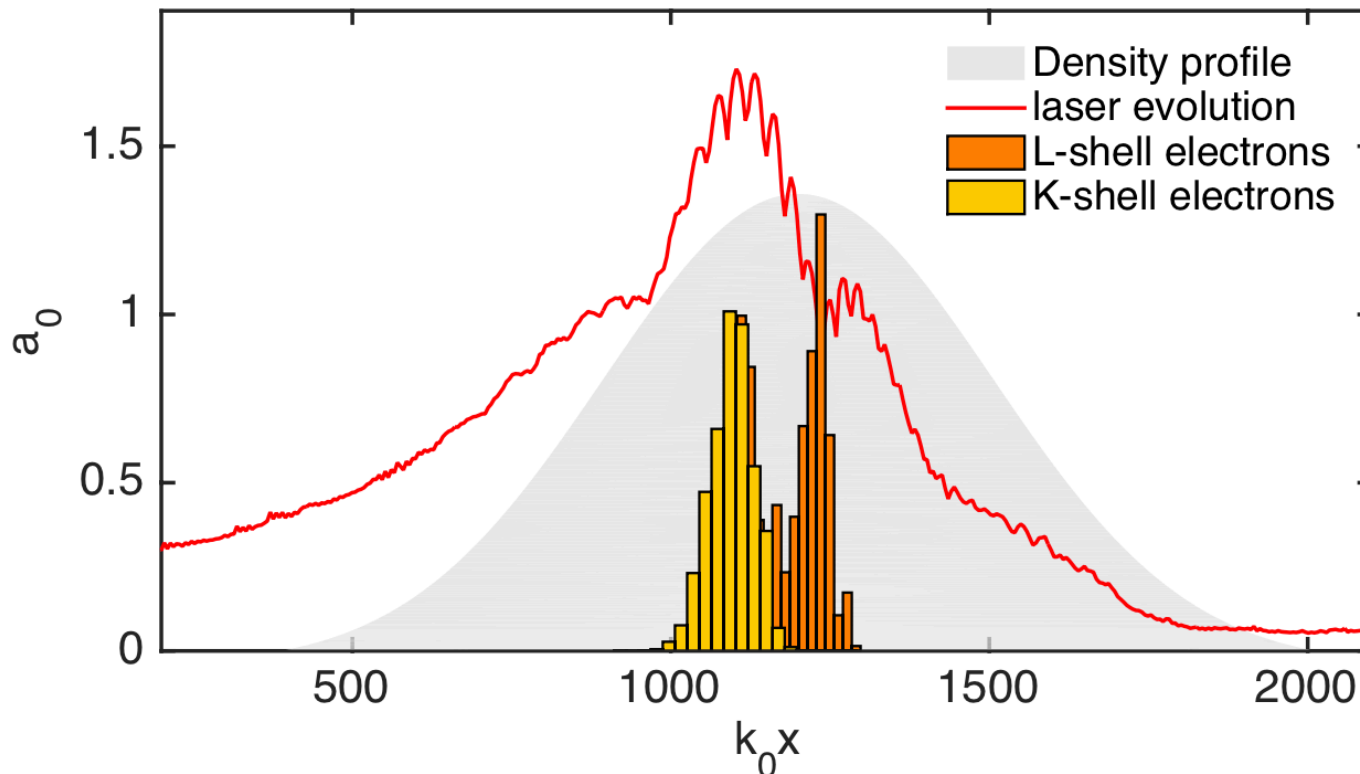
Simulation results  
at the jet exit:

5 MeV beams  
 $\sim$  pC of charge  
20 mrad divergence  
**1 fs duration**

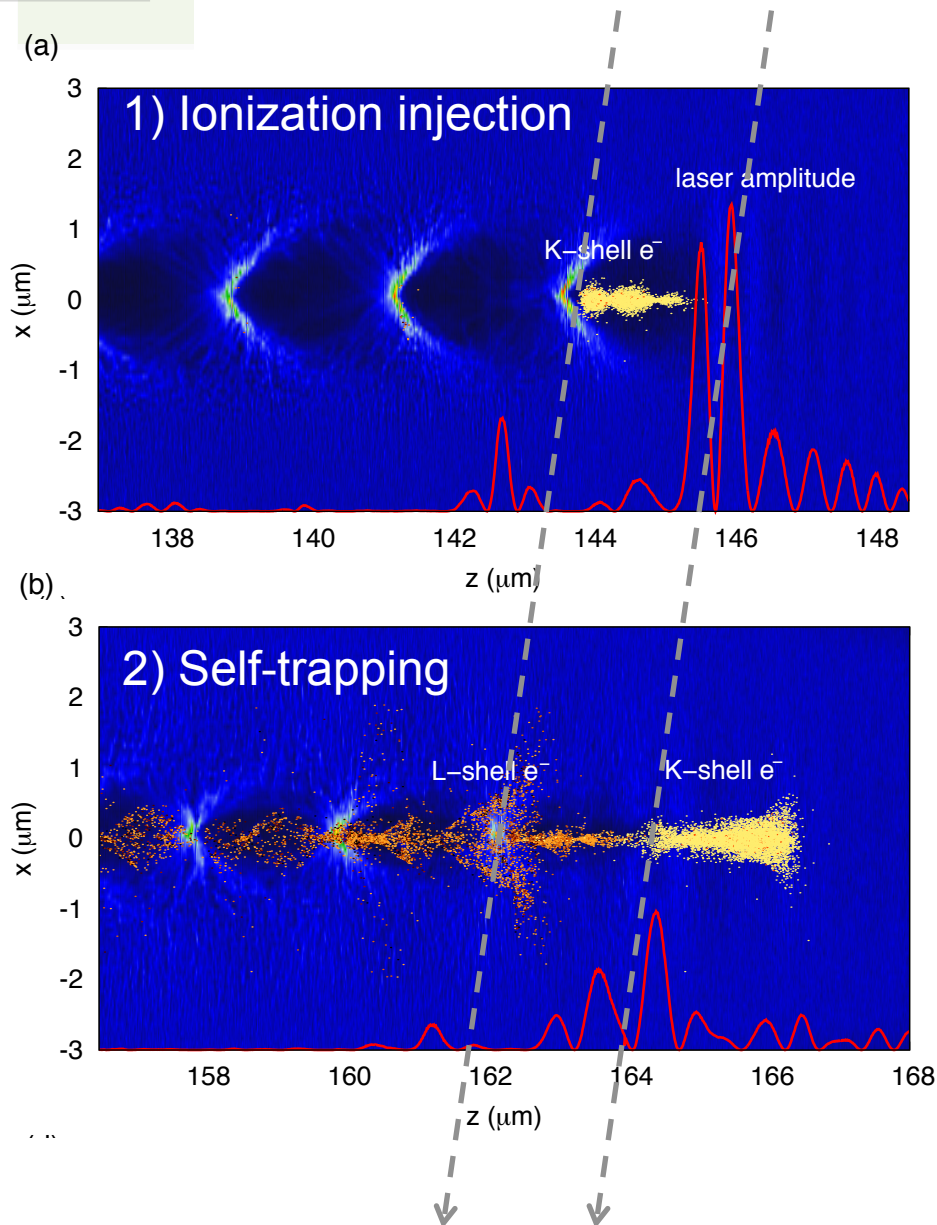
# PIC simulations for supersonic jet case

## → 2 injection mechanisms

Ionization injection is followed by a second injection event  
Less localized than before: Injection length  $L_{inj} > 20 \mu\text{m}$



# High charge due to second injection process



- Red shift of the laser causes
- Slower group velocity
  - Slower wakefield
  - Trapping of  $N^{3+}$ ,  $N^{4+}$  electrons

- Filling up of several plasma buckets: longer electron bunches

# Summary of acceleration mechanisms

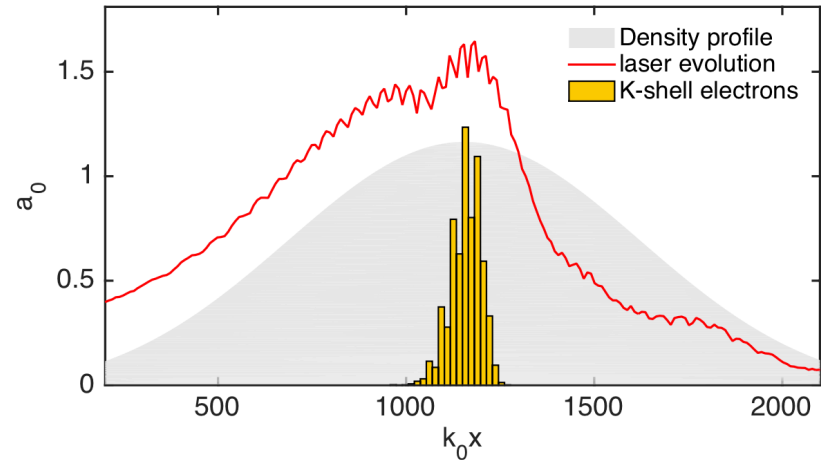
Subsonic jet

$$I = 3 \times 10^{18} \text{ W/cm}^2$$

Local injection

$$L_{\text{inj}} < 10 \mu\text{m}$$

~6 MeV, < pC charge



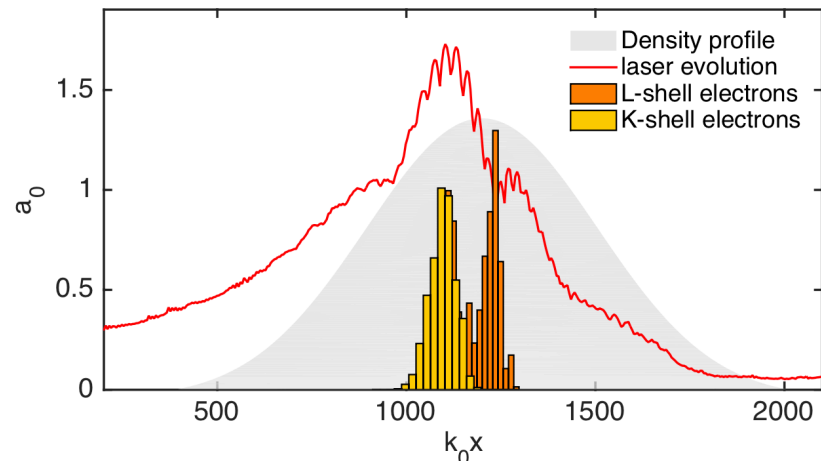
Supersonic jet

$$I = 5 \times 10^{18} \text{ W/cm}^2$$

Non local injection

$$L_{\text{inj}} > 20 \mu\text{m}$$

~3 MeV, >10 pC charge





# Outline of the talk

- Review of experimental results at kHz
- Physics of few cycle laser pulses
  - **Carrier envelope phase effects**
  - Effect of the number of cycles

*Work in progress*

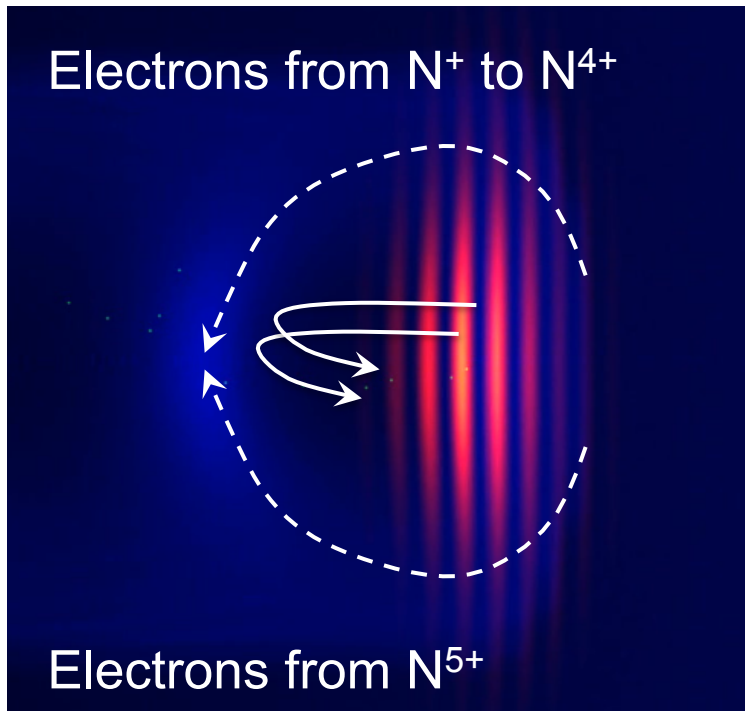


# Expected effect of CEP on acceleration

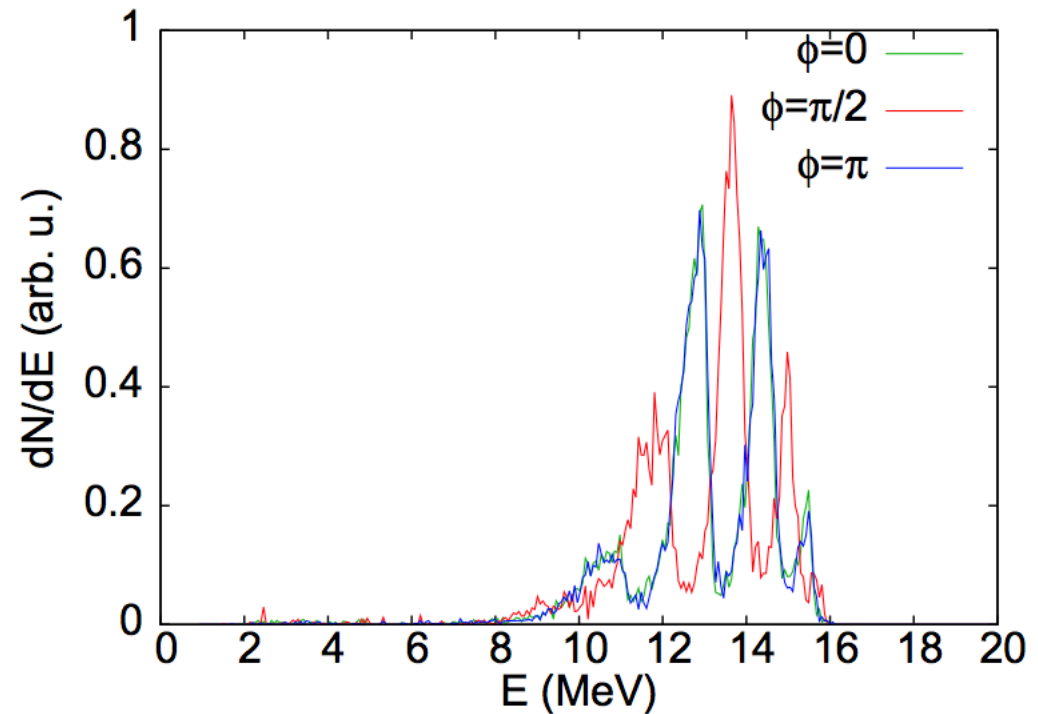
Lifschitz & Malka, NJP 14 053045 (2012)

## Calder-Circ PIC simulations

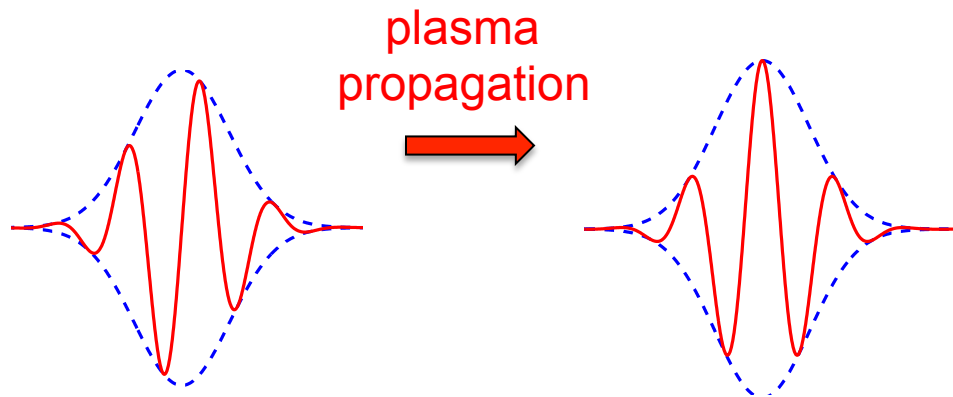
Injection depends on CEP



electron spectra (3D PIC)



# CEP phase slippage



CEP slips because in the plasma

$$v_{\varphi} > v_g$$

The CEP slips by  $2\pi$  after propagation by the **phase slippage length**

$$L_{2\pi} = \lambda_0 \frac{c}{v_{\varphi} - v_g} \simeq \lambda_0 \frac{n_c}{n_e}$$

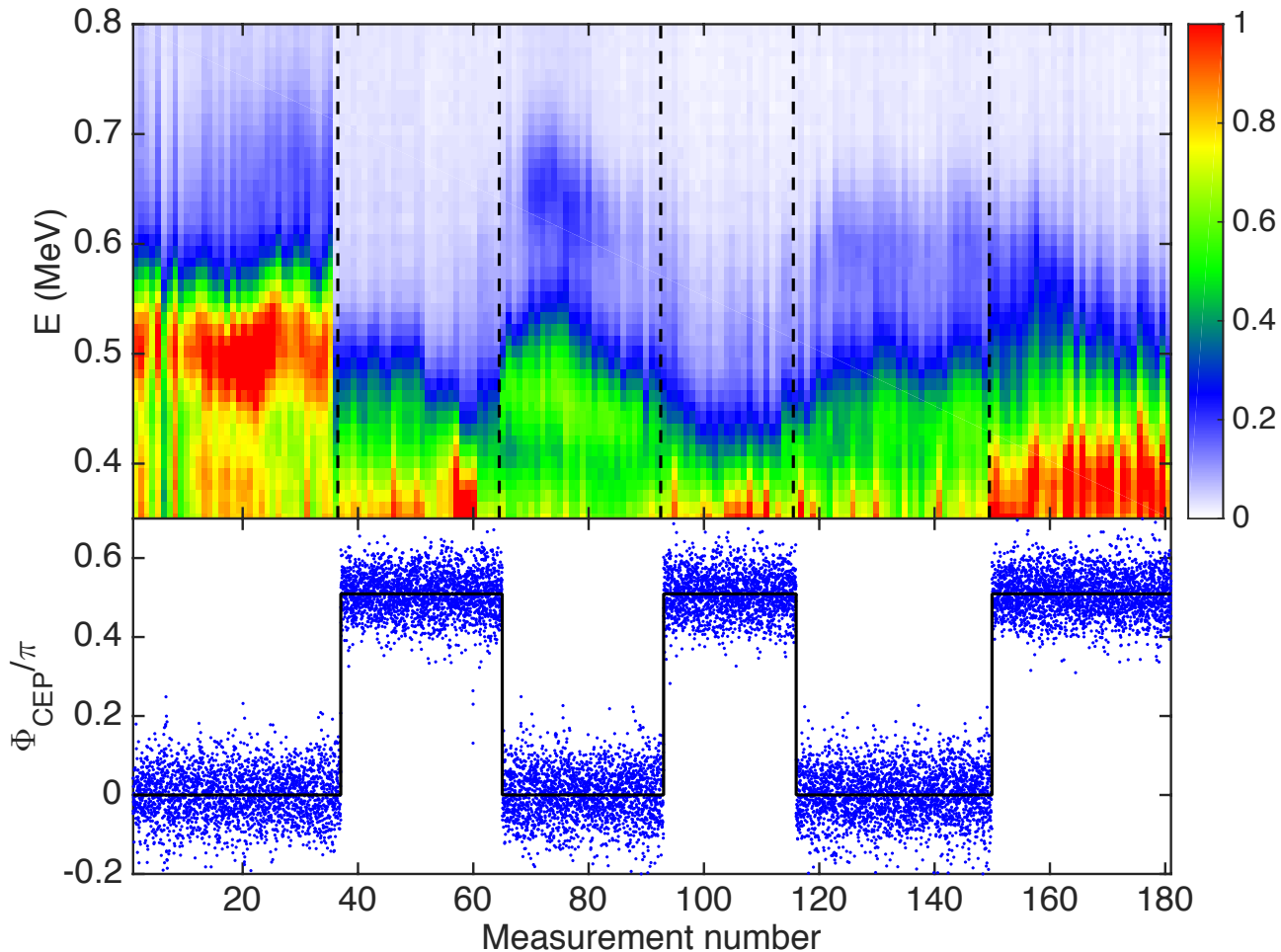
Large effects if **injection length** is smaller than **phase slippage length**

$$L_{inj} \leq L_{2\pi} \simeq 10\mu m$$

Can only be observed in the case of localized ionization injection

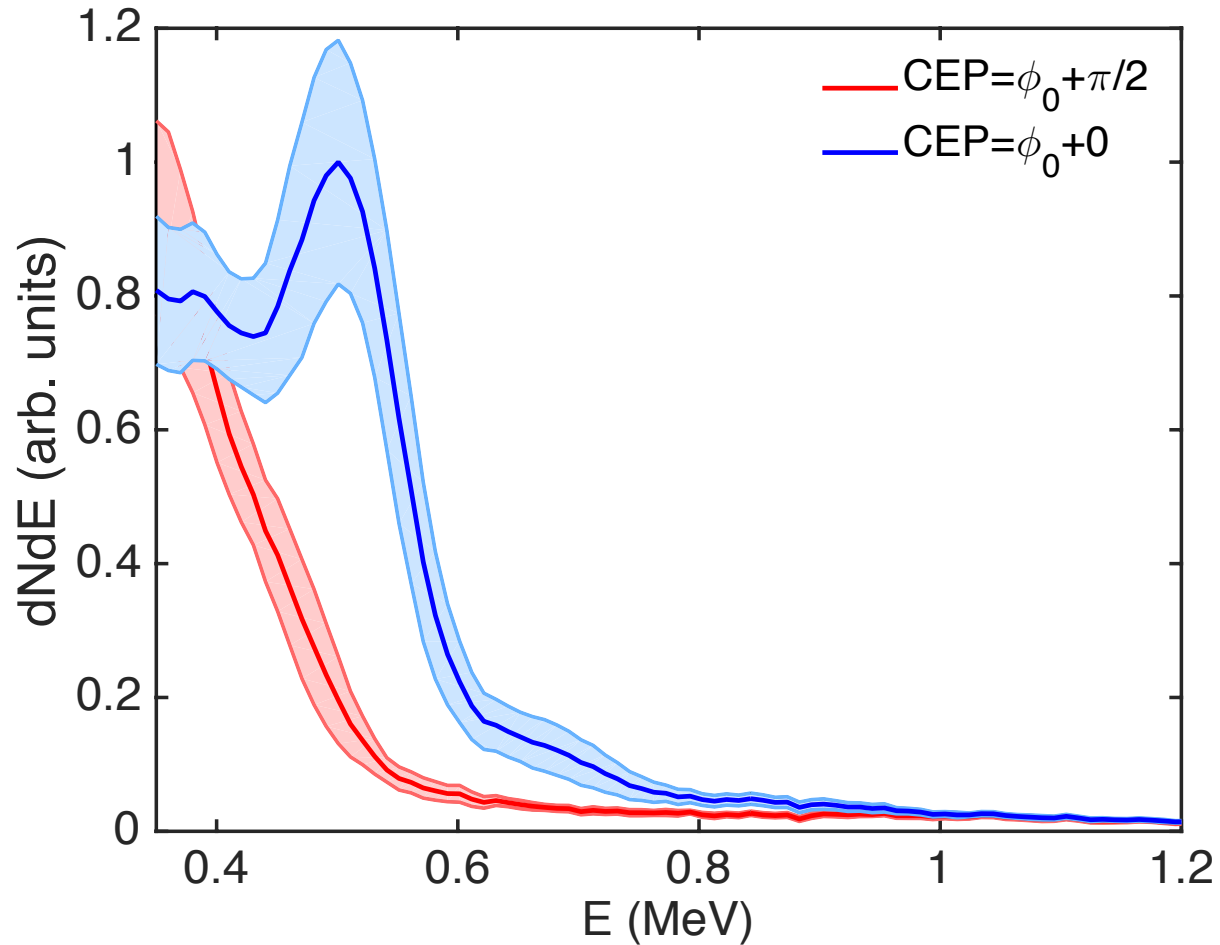
# First clear evidence of the effect of CEP

Clear evidence of CEP effect on cycling from 0 to  $\pi/2$



# Effect of CEP

Averaged spectra (over 40,000 shots)





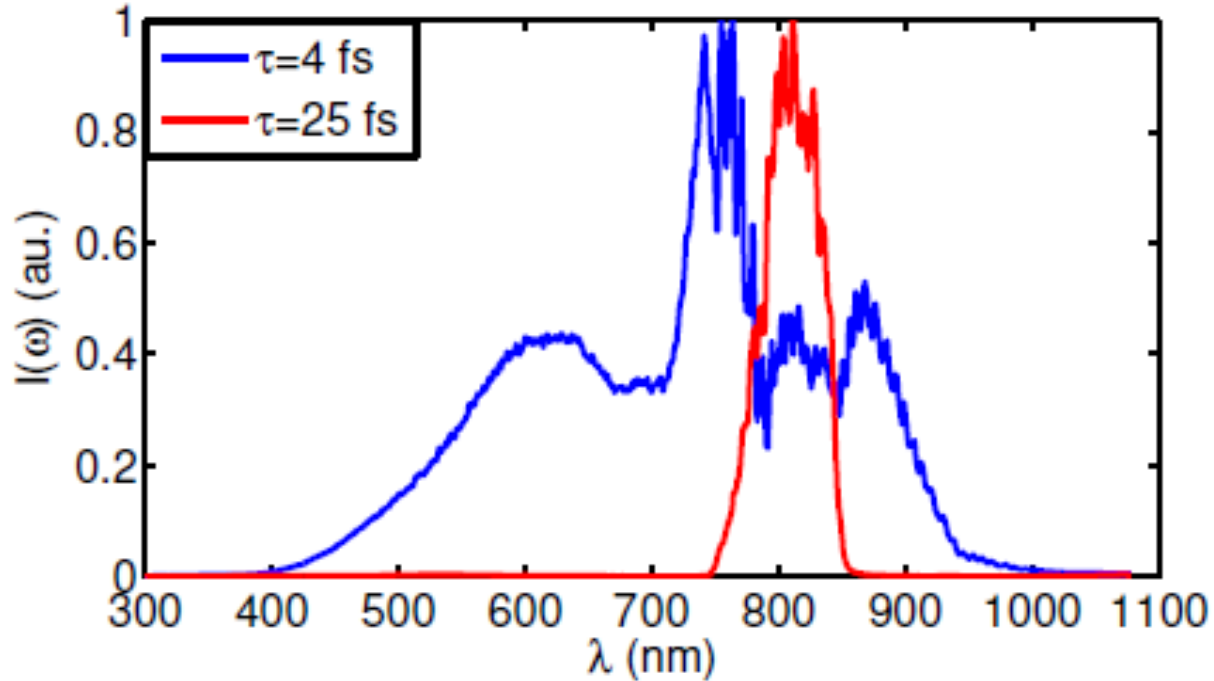
# Outline of the talk

- Review of experimental results at kHz
- Physics of few cycle laser pulses
  - Carrier envelope phase effects
  - **Effect of the number of cycles**

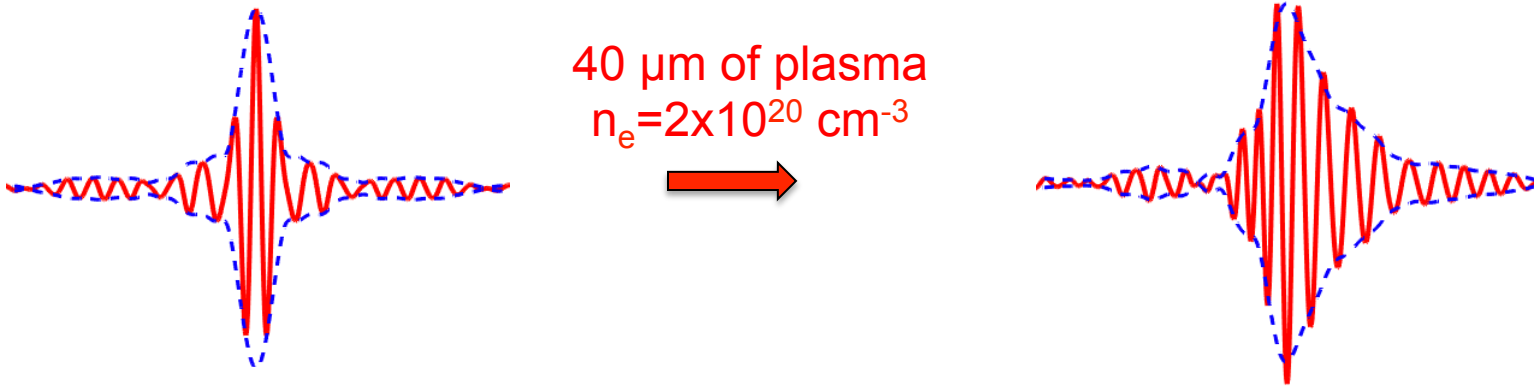
*Work in progress*

# Spectral width and group velocity dispersion

Group velocity dispersion cannot be neglected for single-cycle pulses:



# Group velocity dispersion in the plasma



**dispersion length**

$$L_{disp} = \frac{c\omega_0}{2\Delta\omega^2} \frac{n_c}{n_e}$$

$\Delta\omega$  is the spectral width

$$L_{disp} \simeq 20 \mu\text{m}$$

For 3.5 fs pulses

**Dispersion can be mitigated by using a narrower spectrum**

$$L_{disp} \simeq 100 \mu\text{m}$$

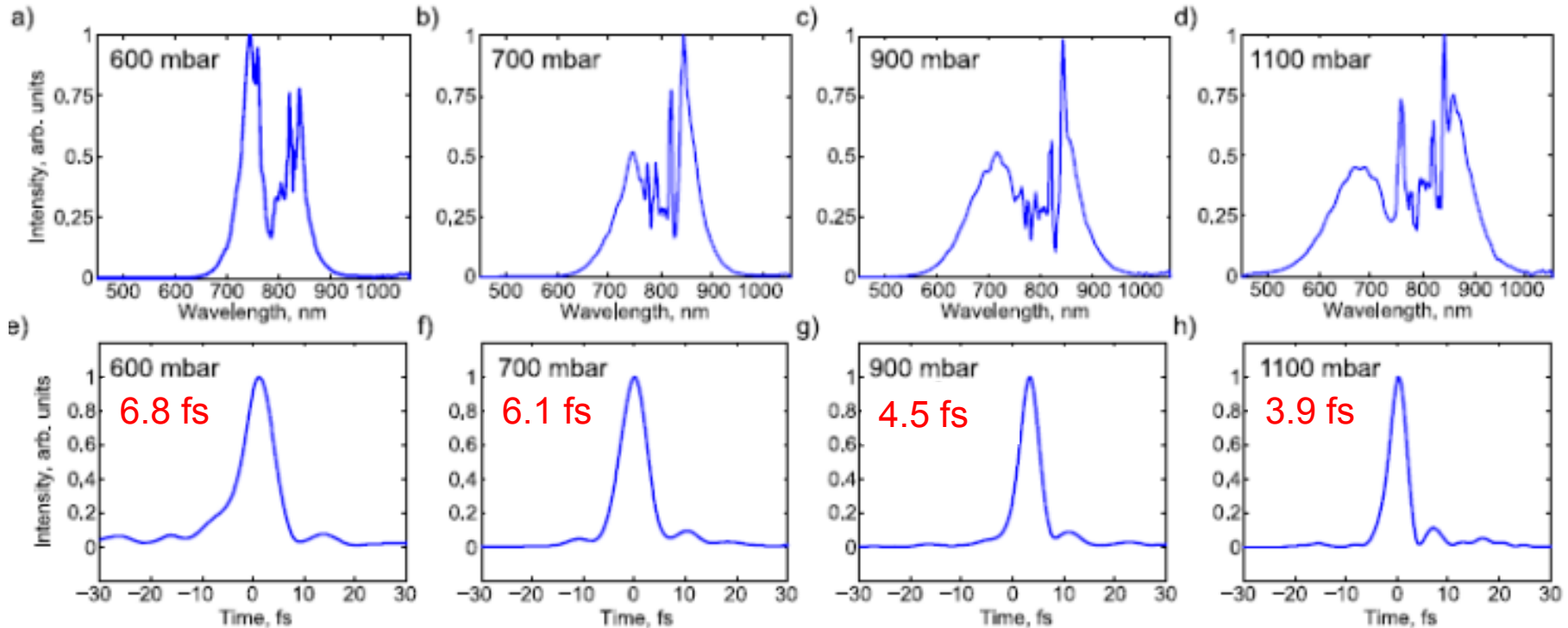
For 7 fs pulses

# Mitigating dispersion with narrower spectrum

Spectrum and transform limited duration can be changed with the pressure in the hollow core fiber

$$L_{disp} \simeq 100\mu m$$

$$L_{disp} \simeq 30\mu m$$



$$1.2 \times 10^{18} \text{ W/cm}^2$$

$$1.6 \times 10^{18} \text{ W/cm}^2$$

$$2.1 \times 10^{18} \text{ W/cm}^2$$

$$2.3 \times 10^{18} \text{ W/cm}^2$$



# Influence of the FTL pulse duration

*Transform limit duration*

3.4 fs

4 fs

5 fs

10 fs

**3.5 pC/shot**

$4.2 \times 10^{19}$

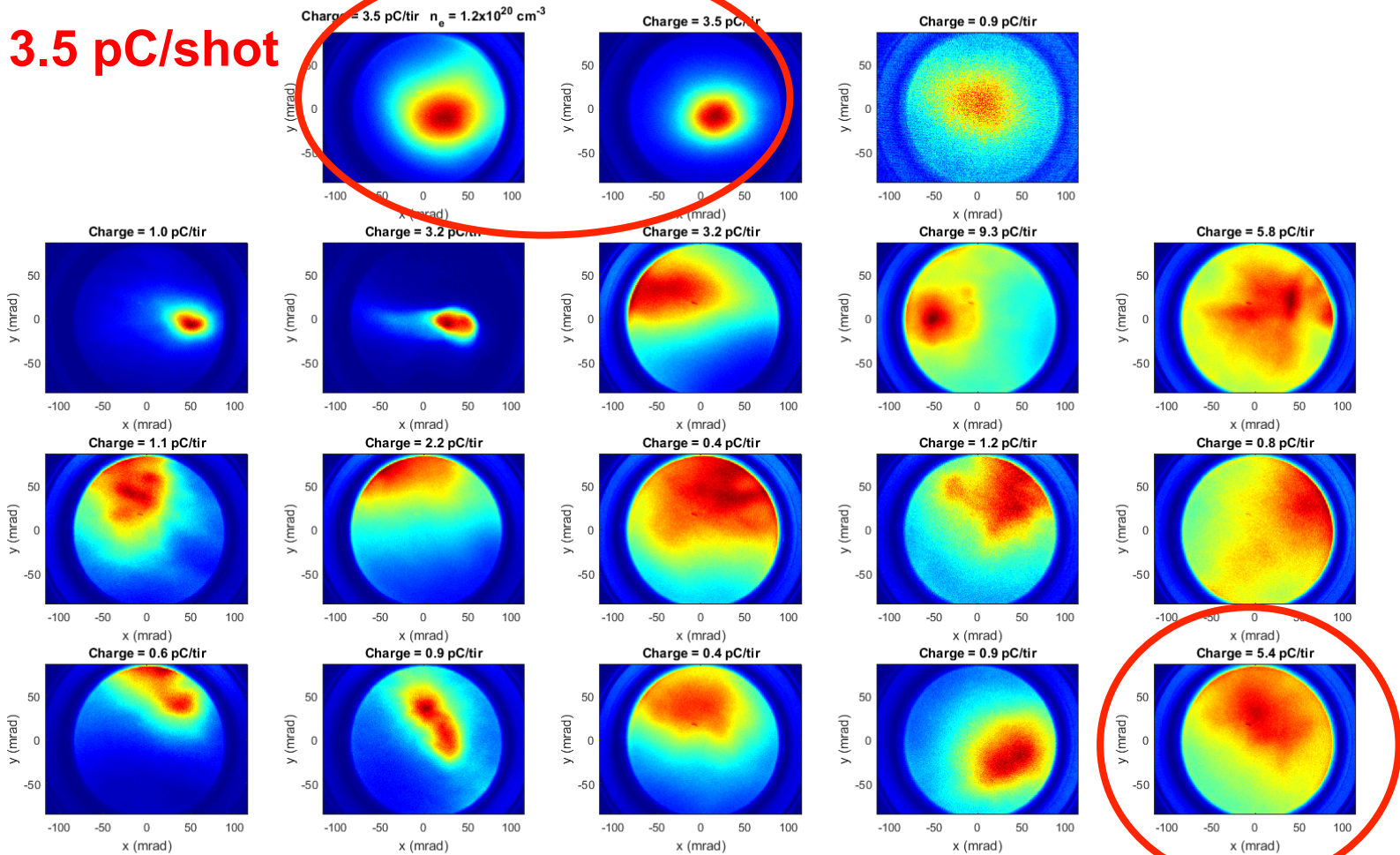
$8.8 \times 10^{19}$

$1.8 \times 10^{20}$

$2.6 \times 10^{20}$

$3.5 \times 10^{20}$

**Electron density ( $\text{cm}^{-3}$ )**



**5.4 pC/shot**

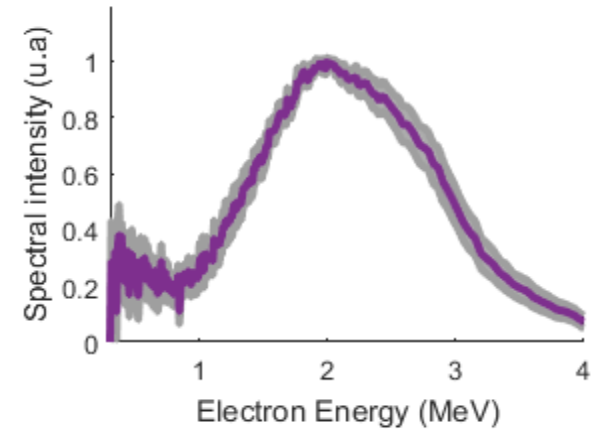
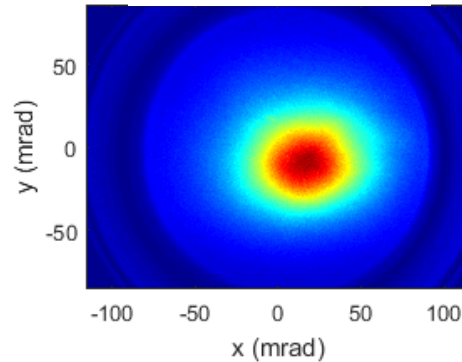
# Importance of self-focusing

3.4 fs case

$$n_e \sim 10^{20} \text{ cm}^{-3}$$

$$P/P_c = 2.5$$

3.5 pc/shot

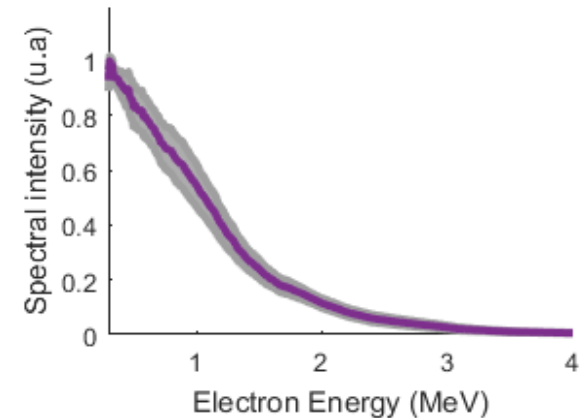
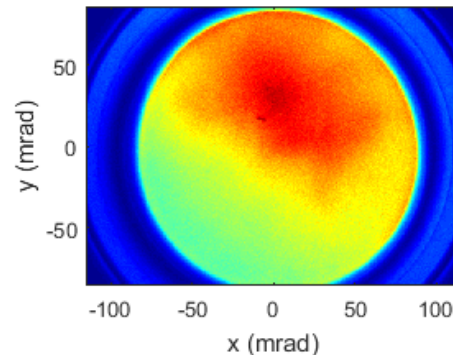


10 fs case

$$n_e \sim 3.5 \times 10^{20} \text{ cm}^{-3}$$

$$P/P_c = 3$$

5.4 pc/shot



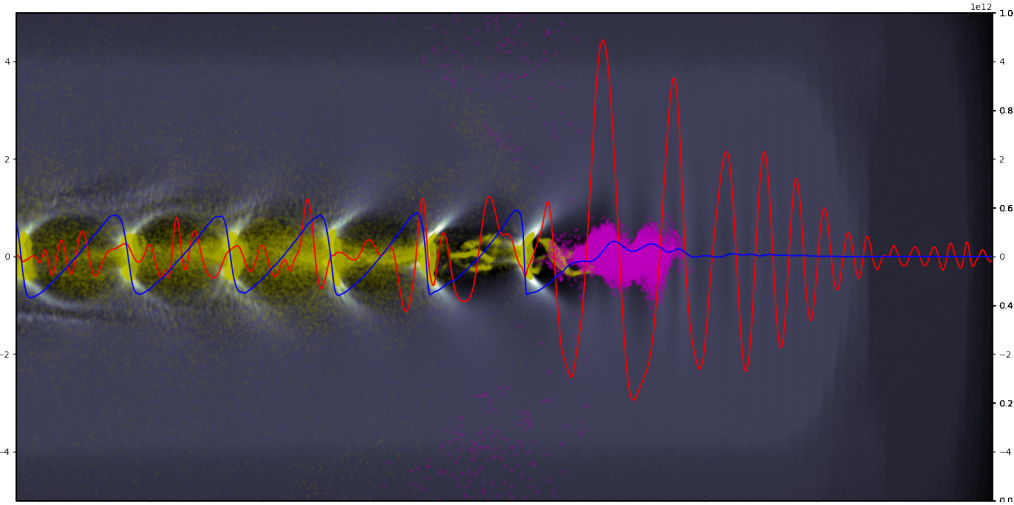
***Still possible to obtain MeV beams with longer pulses and higher density but broad distributions (as in Salehi et al., 2017)***

# PIC simulations (FBPIC, I. Andriyash, Weizmann)

3.4 fs case

$n_e \sim 10^{20} \text{ cm}^{-3}$

$P/P_c = 2.5$

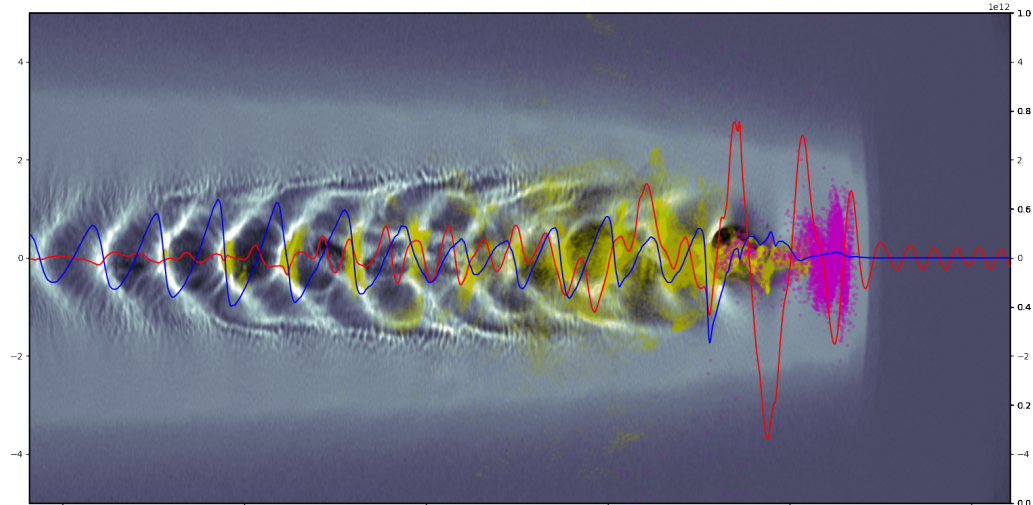


Well defined wake with focusing forces  $\rightarrow$  small divergence

10 fs case

$n_e \sim 3.5 \times 10^{20} \text{ cm}^{-3}$

$P/P_c = 3$



Wake structure is destroyed: large divergence

# Conclusion

- Single-cycle pulses at the resonance give the best electron beams: routine production of **2-5 MeV at kHz**
- Room for improvement in target design for more stable injection, higher resistance to laser flux...
- New physics at the optical cycle to explore: CEP, dispersion...
- **The scaling laws are also valid in the low energy limit**

Ideal parameters for a robust laser driver for 20 MeV electrons @ kHz repetition rate (e. g. for Compton source):

Laser energy: 20-30 mJ

Optimal duration: 7-8 fs

Optimal plasma density:  $6 \times 10^{19} \text{ cm}^{-3}$

Electron energy gain: 20 MeV

Can we do this now ?

# Latest performance of high rep. rate lasers

Ti: sapphire @ 1 kHz: 40 mJ, 29 fs: Jülich laser (THALES)

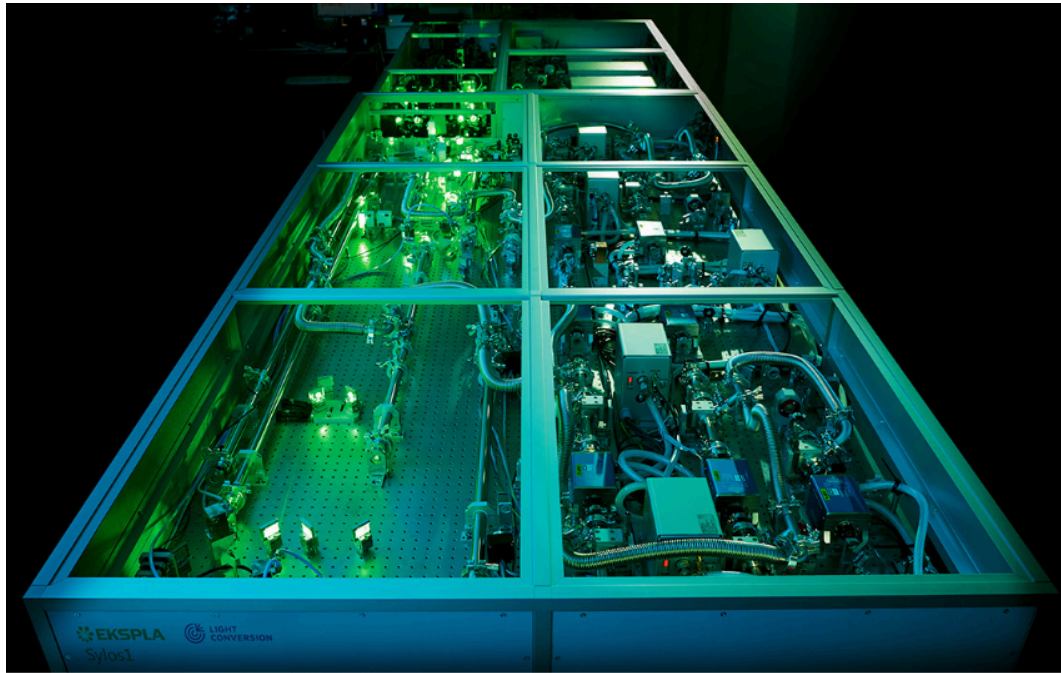


**A good compromise ?** Ti:Sapphire system with >200 mJ,  
30 fs @ **100 Hz** available commercially  
+ use post-compression for sub-10 fs pulses ?



# Latest performance of high rep. rate lasers

OPCPA: 50 mJ, sub-10 fs @ kHz: SYLOS laser, ELI-ALPS



EKSPLA & LIGHT CONVERSION

Ideal on paper, robustness and ease of use for experiments still unknown

→ Large progress in kHz LWFA expected in the next decade

# Collaborators

## **kHz laser-plasma source**

L. Rovige, D. Gustas, D. Guénot, A. Vernier  
B. Beaurepaire, G. Gallé



## **PIC simulations:**

A. Lifschitz, I. Andriyash (Weizmann)

## **Laser system:**

M. Bocoum, F. Böhle, A. Jullien, J.-P. Rousseau  
M. Ouillé, S. Haessler, R. Lopez-Martens

## **Electron diffraction experiments:**

*CUOS of University of Michigan:*

Z. He, A. Thomas, J. Nees, K. Krushelnick



## **Sample preparation**

S. Scott, M. Lagally, Univ. Wisconsin

# Thank you

Contact: [jerome.faure@ensta.fr](mailto:jerome.faure@ensta.fr)

